

_	LA II - AI - AI -	Applicanto
	Application No.	Applicant(s)
	10/743,706	SATO ET AL.
	Examiner	Art Unit
	Sara W. Crane	2811

	SEARCHED				
Class	Subclass	Date	Examiner		
257	72. 59	9/04	SWC		
	75				
	70				
	66				
upda	le	3/05	SWC		

INTERFERENCE SEARCHED					
Class	Subclass	Date	Examiner		
as	above	9/04	SWC		
upda	te	3/05	SWC		
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SEARCH NOTES (INCLUDING SEARCH STRATEGY)					
EAST	DATE	EXMR			
psendo single eryst	al 9/04	SWC			
(laser with recrystal	llization)			
orrentation,					
transistor,					
irregularities,					
Cdifferent adj					
Characteristics					
update	3/05	SWC			
also:					
Haser recrystalliz	ation.				
(differential amp	liker)				
laser + (crystalli inci	nity w eased)	pth)			